

# Table of contents

<b>Acknowledgments</b>	<b>15</b>
------------------------	-----------

<b>Introduction</b>	<b>21</b>
---------------------	-----------

Exploring innovation processes	28
A historiography per element	32
Historical resources	46
Outline of the book	48

---

<b>Business I</b>	
<b>The founding years, 1958-1980</b>	<b>53</b>

Chapter 1	
Joining a revolutionary development, the 1950s	57
Industrial context: Carrying along the rising tide of silicon	57
Corporate course: Arriving during a critical phase in Silicon Valley	59
Elaboration of affairs	63

Chapter 2	
A man of business, 1958-1964	69
Industrial context: A diverging appreciation of silicon	69
Corporate course: Starting from scratch	70
Elaboration of affairs	71

Chapter 3	
The start of Advanced Semiconductor Materials, 1964-1968	84
Industrial context: The advent of chip technology	84
Corporate course: Hedging businesses	87
Elaboration of affairs	88

<i>Intermezzo:</i>	
Emergence of a standard semiconductor product and production methods, 1965-1975	101

Introduction

Chapter 4:	
ASM as original equipment manufacturer, 1969-1974	118
Industrial context: Merchant semiconductor equipment industry	118
Corporate course: Emancipation of a sales agent	119
Elaboration of affairs	120
Chapter 5:	
Globalizing operations, 1975-1977	127
Industrial context: A limited European market	127
Corporate course: Seeking growth abroad	130
Elaboration of affairs	131
Chapter 6:	
Conflicting activities, 1977-1980	138
Industrial context: Rising competition	138
Corporate course: Completing the transition toward equipment Manufacturing	139
Elaboration of affairs	140
Conclusions	146

---

**Innovation I**  
**Manufacturer of chemical vapor deposition  
equipment, 1969-1985** **153**

Chapter 7:	
Atmospheric pressure chemical vapor deposition, 1969-1974	157
Chapter 8:	
Low Pressure Chemical Vapor Deposition, 1974-1978	171
Chapter 9:	
Plasma Enhanced Chemical Vapor Deposition, 1978-1980s	187
Chapter 10:	
Aluminum Chemical Vapor Deposition, 1981-1985	204
Conclusions	222

**Business II**  
**Golden years of expansion, entrepreneurship**  
**and opportunity, 1979-1985** **231**

Chapter 11:  
A thriving market for semiconductor technology, 1979-1983 235  
Industrial context: A resounding technological and industrial dynamism 235  
Corporate course: Scavenging for new inventions to sustain growth 238  
Elaboration of affairs 240

Chapter 12:  
A surging American-Japanese rivalry, 1983-1985 264  
Industrial context: Escalating competition 264  
Corporate course: Reaping fruits 268  
Elaboration of affairs 269

Conclusions 288

---

**Innovation II**  
**Development of the Epsilon epitaxy**  
**reactor, 1982-1988** **293**

Chapter 13:  
Toward an epitaxial reactor, 1970s-1983 300

Chapter 14:  
A competition of enactment, 1983-1986 310

Chapter 15:  
Commercialization of the Epsilon reactor, 1986-1990s 349

Conclusions 363

## **Business III**

### **The game to sustain leveraged innovation, 1985-1992**

**371**

#### Chapter 17:

Ceasing of the American-Japanese rivalry, 1985-1986 375

Industrial context: Rules of play no longer suffice 375

Corporate course: ASM during the downturn 378

Elaboration of affairs 381

#### Chapter 18:

Changing semiconductor production technologies, 1986-1987 388

Industrial context: A new dynamism 388

Corporate course: Anticipating commercial opportunities and technological developments 390

Elaboration of affairs 391

#### Chapter 19:

Derailing external and internal events, 1987-1992 402

Industrial context: Balancing on quicksand 402

Corporate course: Dealing with Dutch drag 403

Elaboration of affairs 409

Conclusions 438

---

## **Innovation III**

### **Innovation strategy, governmental support and defiant realities, 1979-1993**

**445**

#### Chapter 20:

Economic policies and governmental support, 1979-1984 452

#### Chapter 21:

A new innovation strategy, 1984-1988 465

#### Chapter 22:

The (un)fulfilment of a promise, 1988-1993 482

Conclusions 508

**Business IV**  
**Contemplation and core competencies, 1992-1999** **517**

Chapter 23:	
Hitting bottom, 1992-1994	522
Industrial context: A downward spiral	522
Corporate course: Draining a poisoned cup	527
Elaboration of affairs	532
Chapter 24:	
The only way is up, 1994-1996	549
Industrial context: A most welcome revival	549
Corporate course: Regained confidence and aligning forces	552
Elaboration of affairs	558
Chapter 25:	
Prospects put into perspective, 1996-1999	587
Industrial context: Harmonization and destabilization	587
Corporate course: When ASM Pacific Technology sneezes, all of ASM International gets a cold	590
Elaboration of affairs	592
Conclusions	609

---

**Innovation IV**  
**Enacting high-k gate dielectrics and atomic  
layer deposition technology, 1996-2007** **617**

Chapter 26:	
Pursuing integrated and rapid thermal processes, 1995-1999	627
Chapter 27:	
Enacting atomic layer deposition for high-k, 1999-2001	644
Chapter 28:	
Integrating high-k into production, 2001-2007	670
Conclusions	694

**Business V**  
**Finding a balance between sustaining and**  
**disrupting technologies, 1999-2008** **703**

Chapter 30:  
Surging ahead, 1999-2001 708  
Industrial context: The Dotcom Boom 708  
Corporate course: Ongoing expansion 715  
Elaboration of affairs 717

Chapter 31:  
Redefining foundations, 2001-2004 738  
Industrial context: From Boom to Bust 738  
Corporate course: Biding time 742  
Elaboration of affairs: 744

Chapter 32:  
A shake up, 2004-2008 760  
Industrial Context: Separating the sheep from the goats 760  
Corporate course: A dynamic finale 764  
Elaboration of affairs 768

Conclusions 801

---

**Epilogue** **809**

Industrial context 811  
Corporate course 820  
Entrepreneurial perils 828  
Conclusions 830

**Conclusion 833**

Characterization of ASM's innovation processes	834
Explanation of ASM's innovation process	840
Explaining with path	840
Explaining with fortuna	852
Explaining with virtù	855
Grasping innovation through business and technology	860

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**Afterword 863**

Fortuna	866
Virtù	869
Path	871
Inventing an author	876

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**Historical resources 879**

**Timeline 921**

**Abbreviations 925**

**Glossary 930**

**Business index 940**

**Name Index 947**